## Synthesis and fluorescence properties of nanoisland-structured SiO<sub>x</sub>/Cu<sub>x</sub>O composite

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Figure S1. XPS narrow scan spectrum of F 1s of freshly prepared nanoisland  $SiO_x/Cu_xO$  composite.



**Figure S2.** SEM image of the surface of the 3-min Cu deposited Si wafer. The bright part is the deposited Cu and the dark part is the crack structure among isolated Cu blocks.



**Figure S3.** SEM images of various samples prepared by different Cu coating conditions. Upper left: 15-min Cu coated sample; Upper right: 10-min Cu coated sample; Bottom left: 5-min Cu coated sample; Bottom right: enlarged SEM image of 5-min Cu coated sample (the preparation conditions are as the same as those for preparation of nanoisland  $SiO_x/Cu_xO$  composite).

1
(%)

**Table S1.** EDS quantitative analysis of different regions of the prepared nanoisland  $SiO_x/Cu_xO$  composite: (a) EDS quantitative analysis of the protuberance region; (b) EDS quantitative analysis of the connection region between two protuberances.